Electronic Pate	ent App	olication Fee	Transmit	tal				
Application Number:	10:	10576321						
Filing Date:	19-	19-Apr-2006						
Title of Invention:	PR	PROCESS FOR PRODUCING HIGH-RESISTANCE SILICON WAFERS AND PROCESS FOR PRODUCING EPITAXIAL WAFERS AND SOI WAFERS (AS AMENDED)						
First Named Inventor/Applicant Name:	Ka	Kazunari Kurita						
Filer:	Ch	Christopher W. Brody/Melissa Garton						
Attorney Docket Number:	120	12054-0059						
Filed as Large Entity								
U.S. National Stage under 35 USC 371 Fi	ling Fee	S						
Description		Fee Code	Quantity	Amount	Sub-Total in USD(\$)			
Basic Filing:								
Pages:								
Claims:								
Miscellaneous-Filing:								
Petition:								
Patent-Appeals-and-Interference:								

Post-Allowance-and-Post-Issuance:

Utility Appl issue fee

Publ. Fee- early, voluntary, or normal

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Extension-of-Time:				
Miscellaneous:				
	Total in USD (\$)			1810